



The Silicon TPC System (SITPC)

EUDET Annual meeting
9 October 2007

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NIKHEF

JRA2 activity/task

- Silicon TPC readout (“SiTPC”)
 - development MediPix → TimePix chip
 - development diagnostic endplate module
incl. DAQ

Purpose: a SiTPC based monitoring system

Partners:

ALU Freiburg, Bonn, CEA Saclay, CERN, NIKHEF

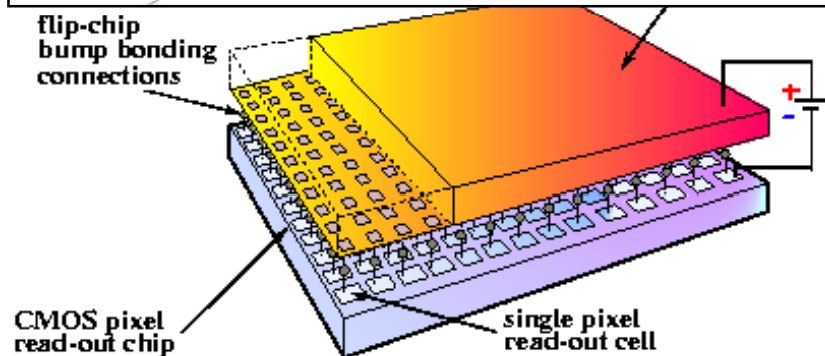
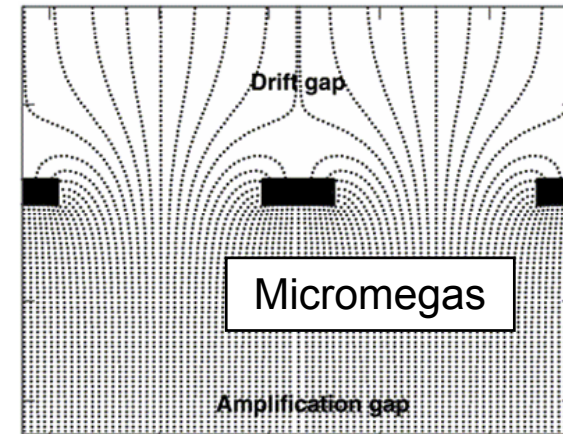
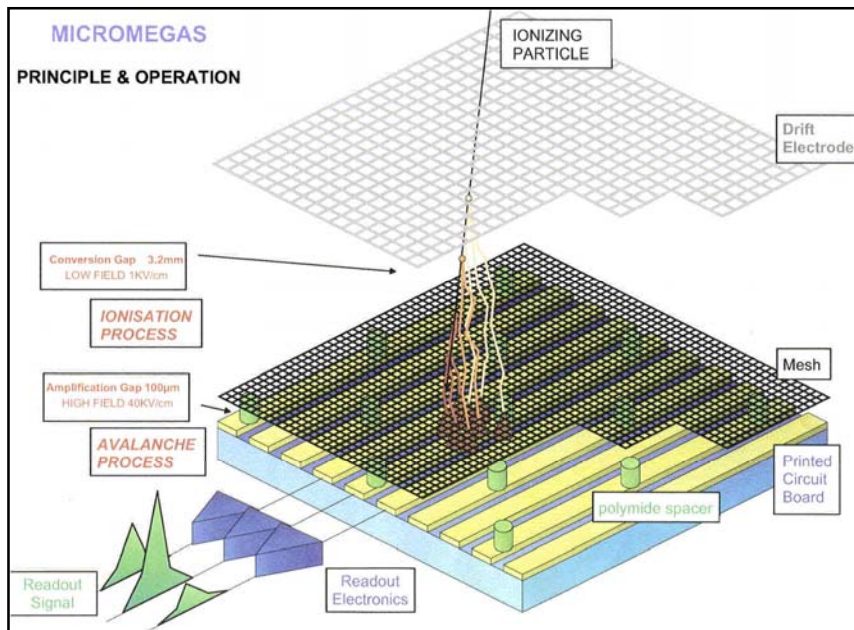
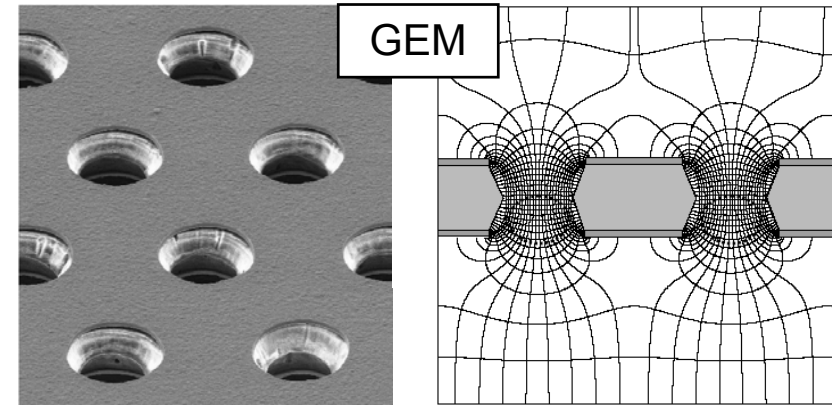
Associate: Bucarest

SITPC Tasks:

- ✓ Develop the Timepix chip that allows to measure the 3rd coordinate (drift time)
- ✓ Implementation of Timepix together with GEM and Micromegas into diagnostic endplate system (in progress)
- ✓ Performance measurements in test infrastructure at DESY and other places (in progress)
- Develop simulation framework
- Develop DAQ system and integrate in overall DAQ of EUDET infrastructure

Micro Patterned Gaseous Detectors

- High field created by Gas Gain Grids
- Most popular: GEM & Micromegas



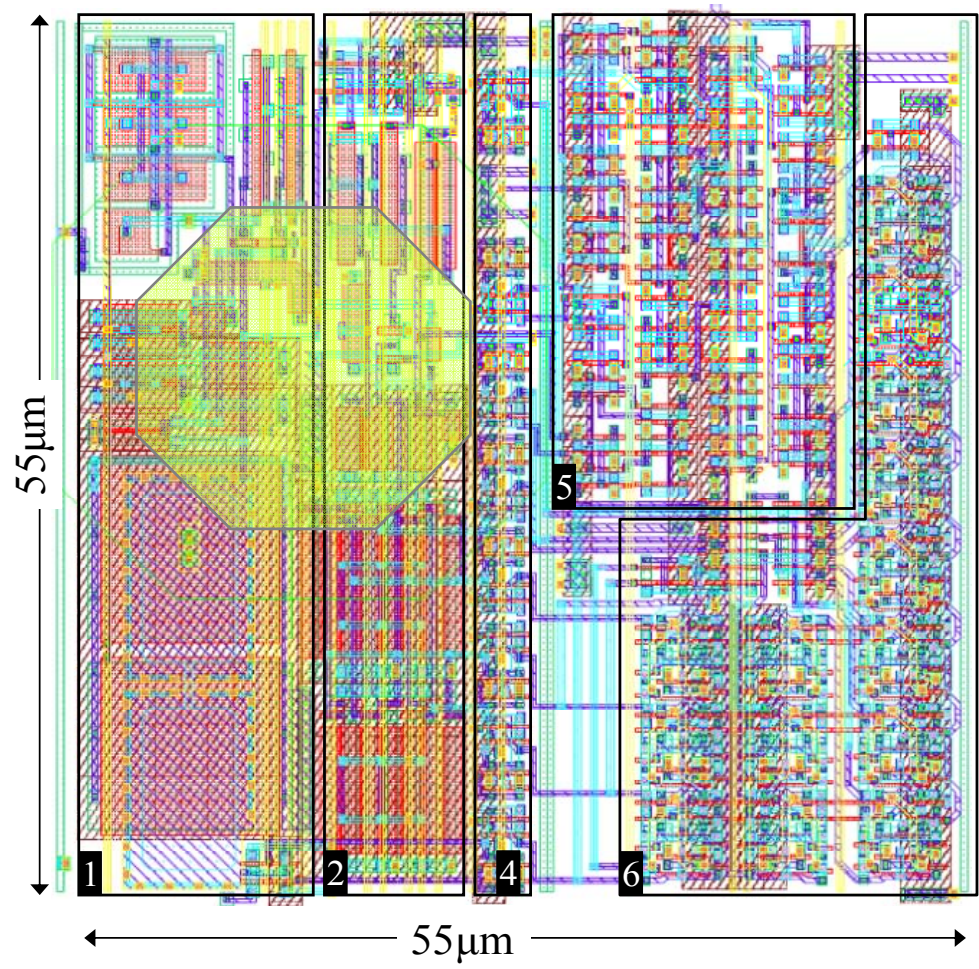
Use 'naked' CMOS pixel readout chip as anode



Timepix pixel

55x55 μm^2

CERN

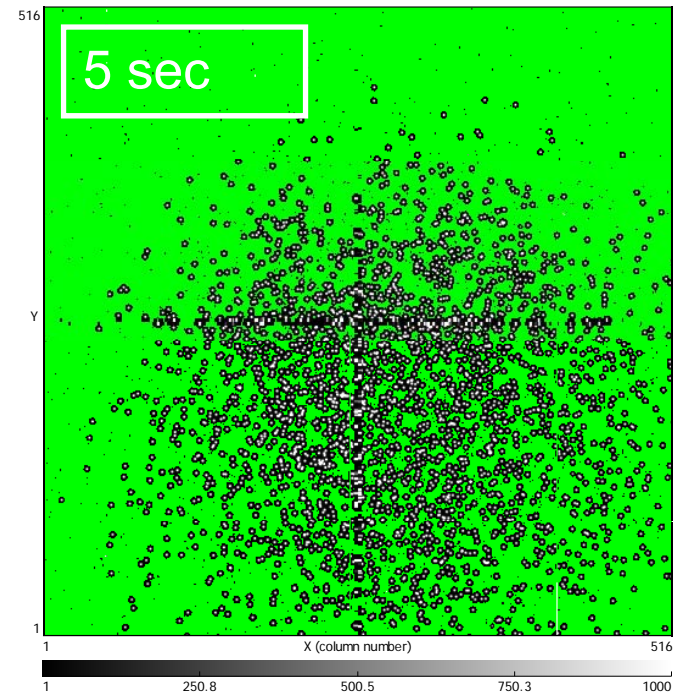
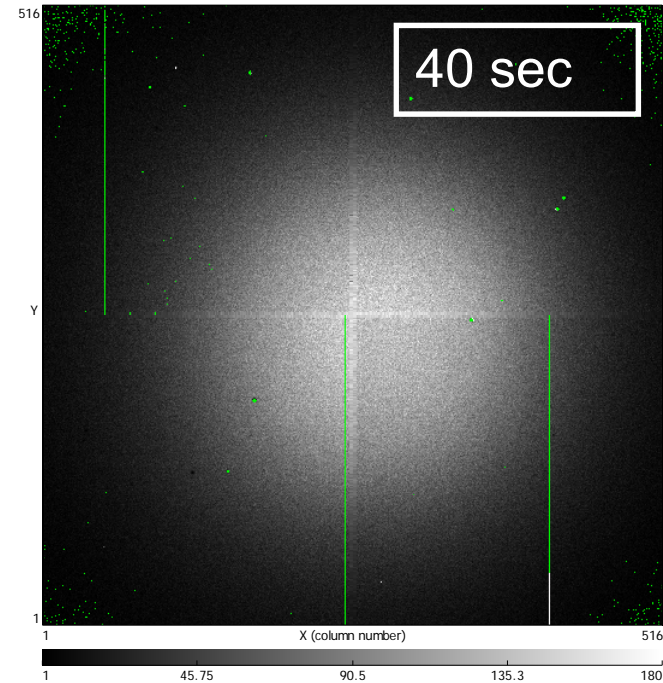
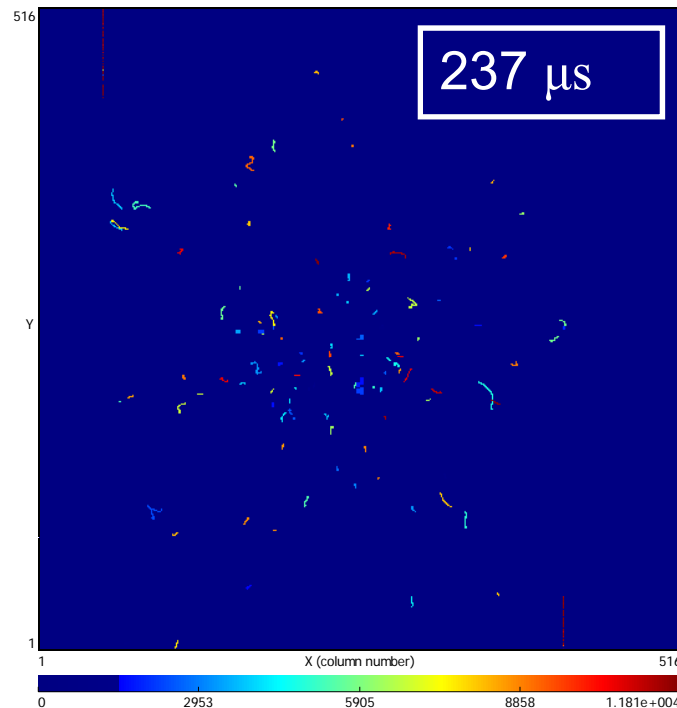


Timepix chip (1st version) produced Sept. 2006

Available for use in detectors since Nov. 2006

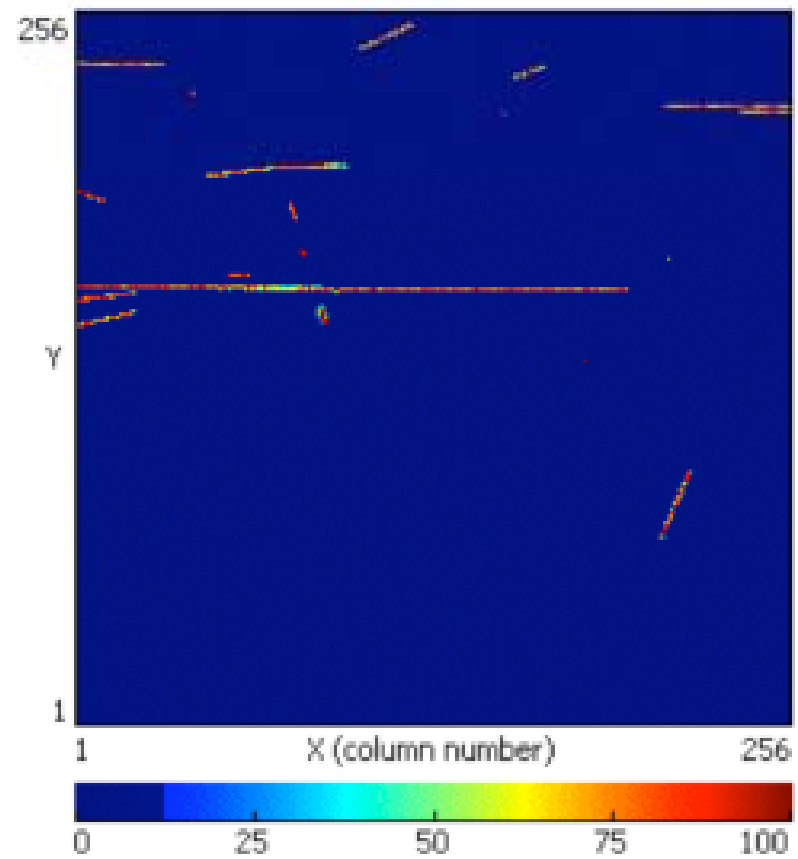
CERN (Xavi Llopart/Michael Campbell):
first Timepix quad (+ 300 μm Si sensor)

- Top-right: Medipix counting mode (^{55}Fe)
- Bottom-left: Time mode (^{90}Sr)
- Bottom-right: time-over-threshold (^{241}Am)



Erik Heijne: Timepix (single chip + Si sensor) parallel to beam

H6 120 GeV/c PION BEAM



ANALOG MODE TOT
TYPICAL SIGNAL ~80 counts



Timepix in gaseous detectors

- With GEM stacks or Micromegas
- Wafer postprocessing:
 - Enlarged pixels
 - Integrated grid
- Discharge protection

DESY Test Beam June 2007

(before the end of HERA...)

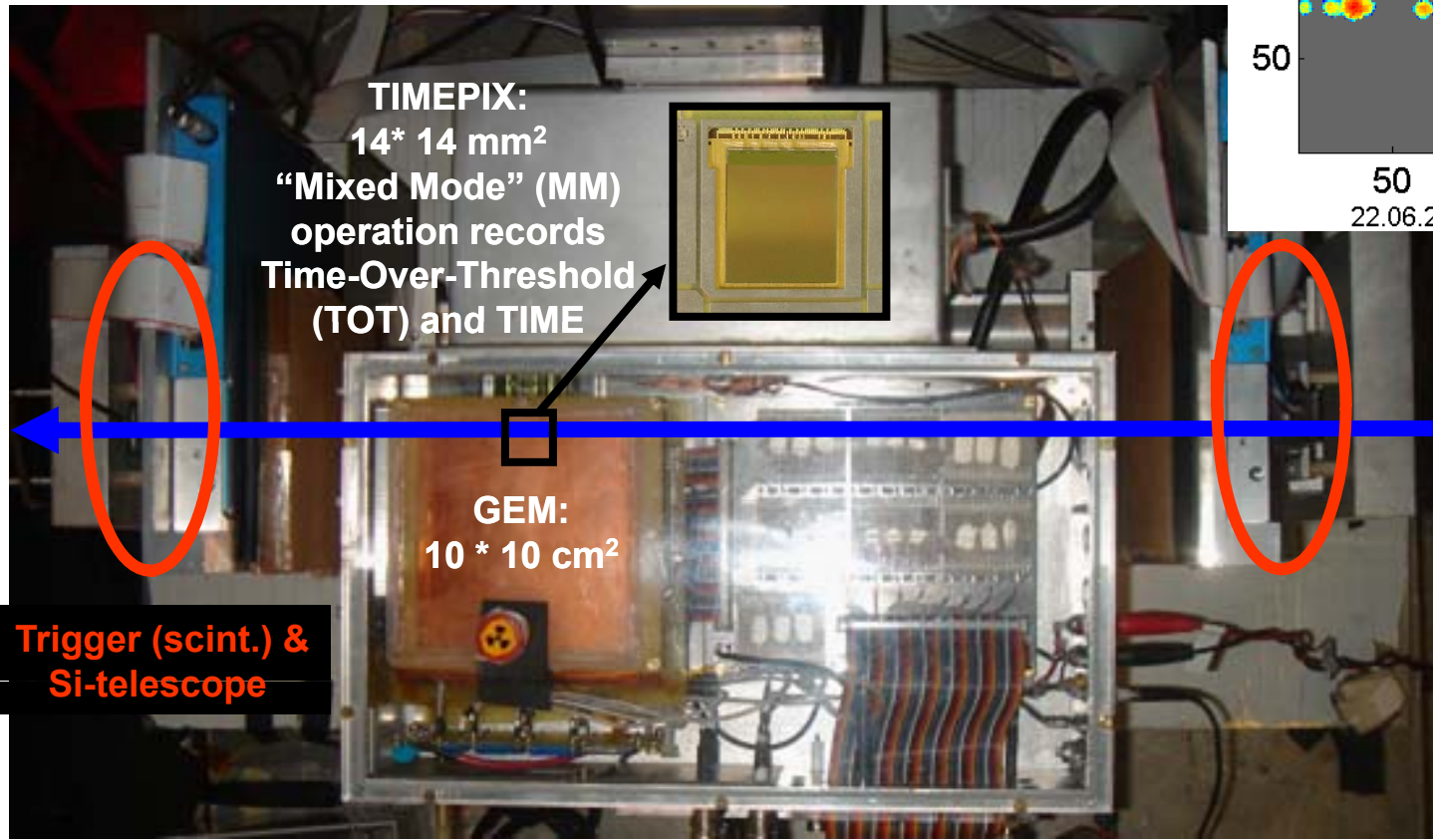
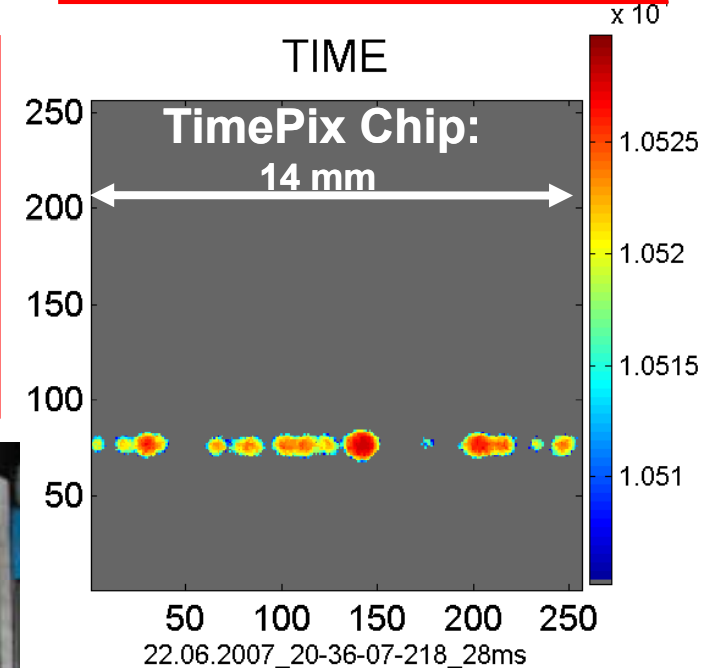
Freiburg (+Bonn)

Several mixtures studied:

- Ar/CO₂ (70:30)
- He/CO₂ (70:30)
- He/CO₂/C₄H₁₀ (68:30:2)
- Ar/He/CO₂ (60:10:30)
- TDR

Two different GEM types tested:

- Standard 100x100mm² GEMs with 140μm hole pitch
- New 24x28mm² GEMs with 50μm hole pitch



e- beam DESY II

AGAIN VERY ROBUST (TIMEPIX) OPERATION FOR BOTH GEM TYPES

Trigger (scint.) & Si-telescope

Resolution studies



Spatial resolution $\sigma_{mean}^2 = \sigma_0^2 + \frac{D_t^2 \cdot y}{n_{cl}^{el}}$

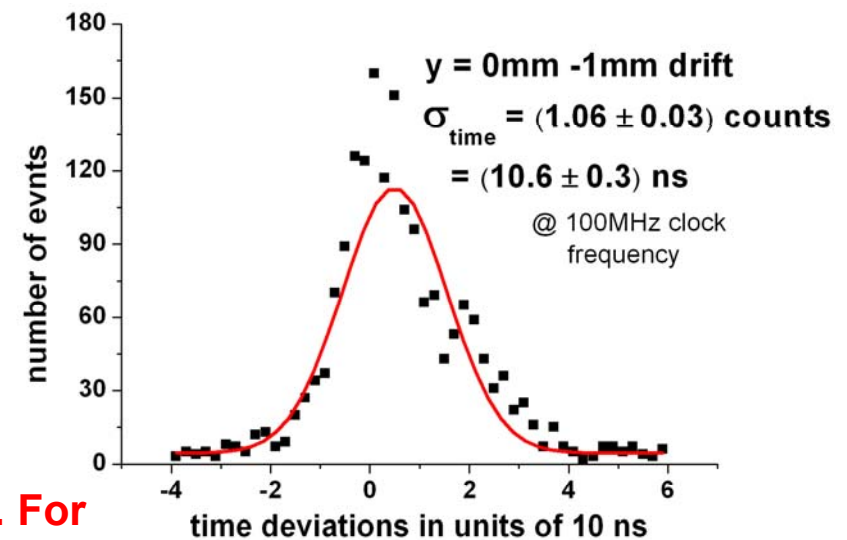
- D_t - transverse diffusion coefficient
- n_{cl}^{el} - number of primary electrons per cluster
- y - drift length

• $\sigma_0 \approx 15-25\mu m$

Clustering method	Gas	DATA		Simulations	
		σ_0	$\frac{D_t^2}{n_{cl}^{el}}$	σ_0	$\frac{D_t^2}{n_{cl}^{el}}$
"Island"	Ar/CO ₂	21.7 +/-0.5	519 +/-12	-----	-----
	He/CO ₂	25.6 +/-1.0	675 +/-16	-----	-----
	new GEM type Ar/CO₂	15.4 +/-0.4	405 +/-10	-----	-----
"Saddle Point"	Ar/CO ₂	18.4 +/-2.7	467 +/-36	15.2 +/-3.8	726 +/-41
	He/CO ₂	27.1 +/-4.9	547 +/-78	19.4 +/-4.0	989 +/-54

Time resolution

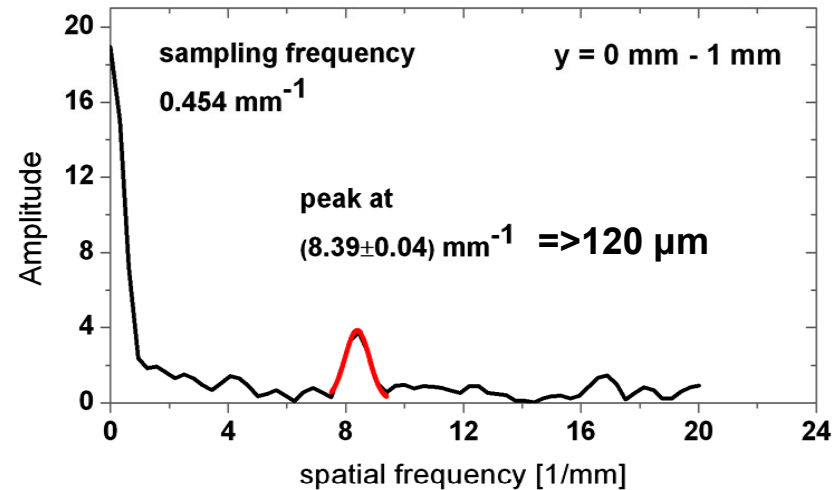
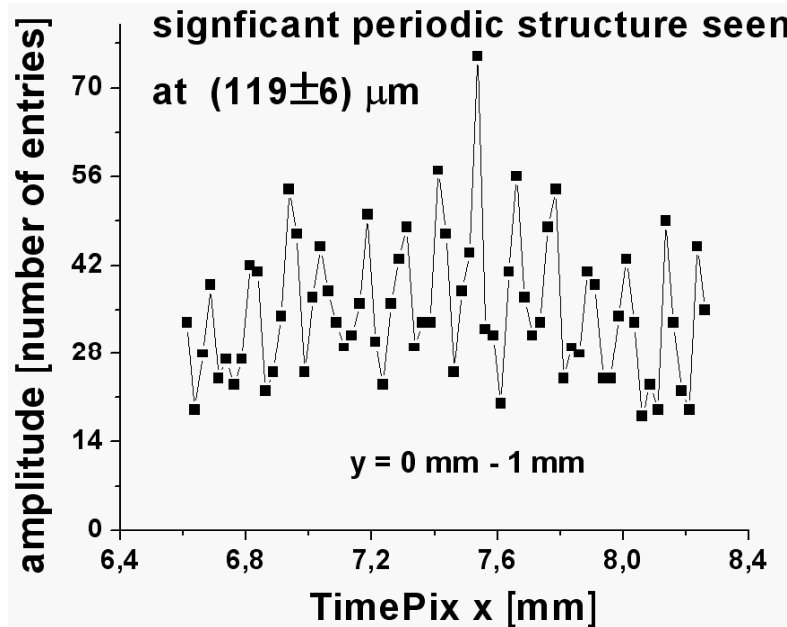
Time resolution was evaluated in MM-operation. A correlation between TOT-maximum and Time was used to correct for time-walk problems (typically 2-3 counts).



Proves robustness of cluster separation algorithms. For σ_0 good agreement between experiment and simulations. D_t^2/n_{cl}^{el} is in fair agreement.

Substructure due to GEM hole pitch

standard GEM



Is the resolution of a cluster yet affected by the finite pitch of the holes?

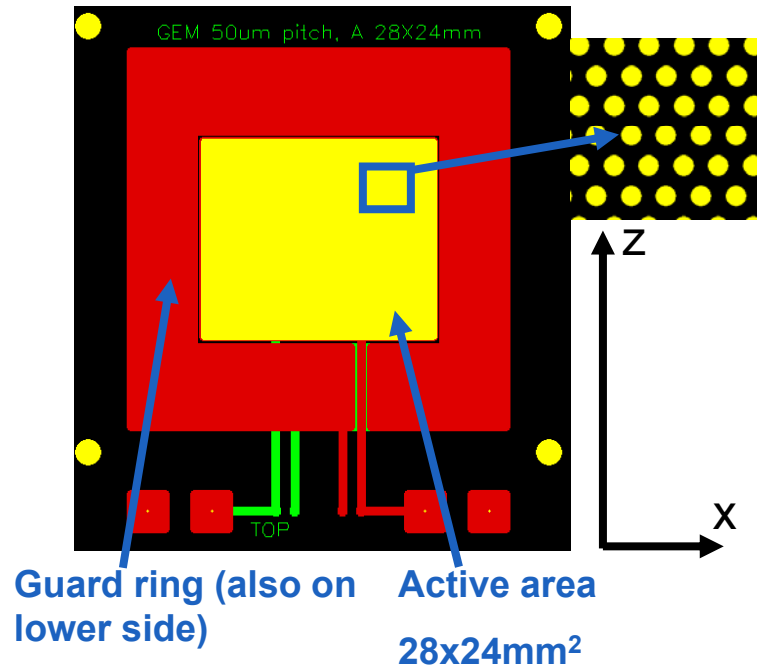
Test runs are taken recently with different orientation with respect to the track and with smaller pitched GEMs ($80\mu\text{m}$).

Results are expected to be available soon.



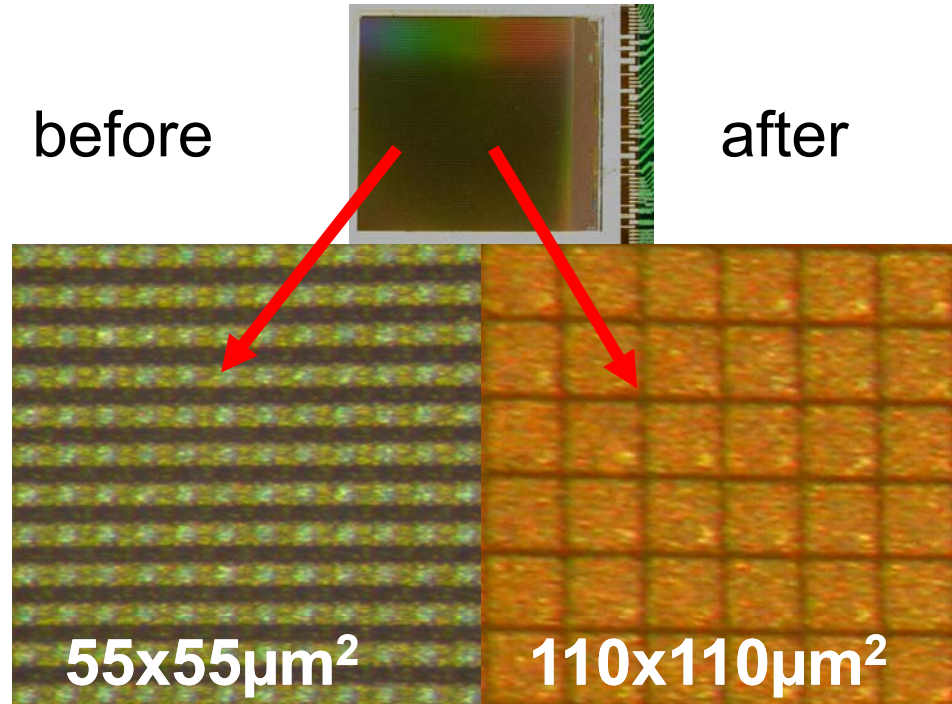
New Technical Developments

New GEM type



- Nominal outer hole diameter 30µm in copper
- Inner hole sizes are as small as 17µm-21µm in the Kapton
- Pitch of holes 50µm
 - Projected in x \approx 43µm
 - Projected in z \approx 25µm

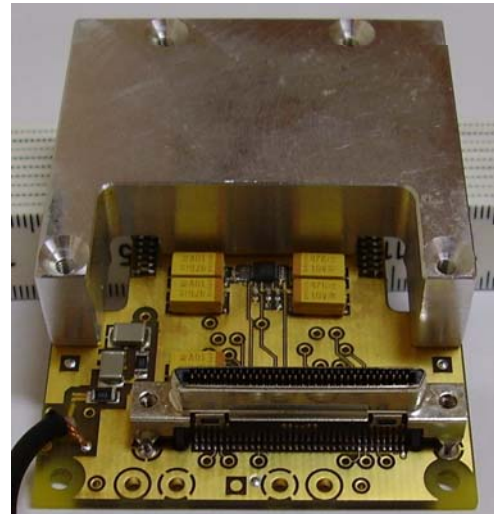
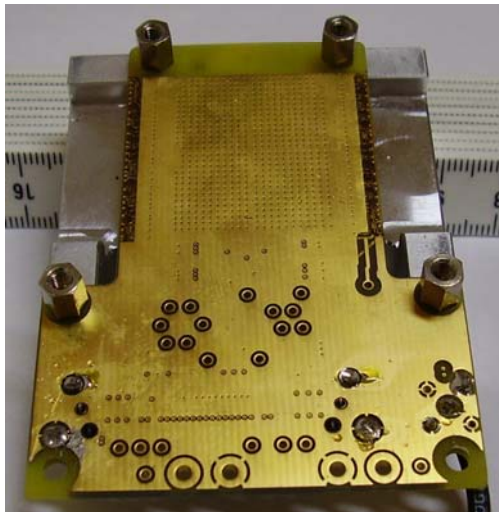
Post processing on a single chip



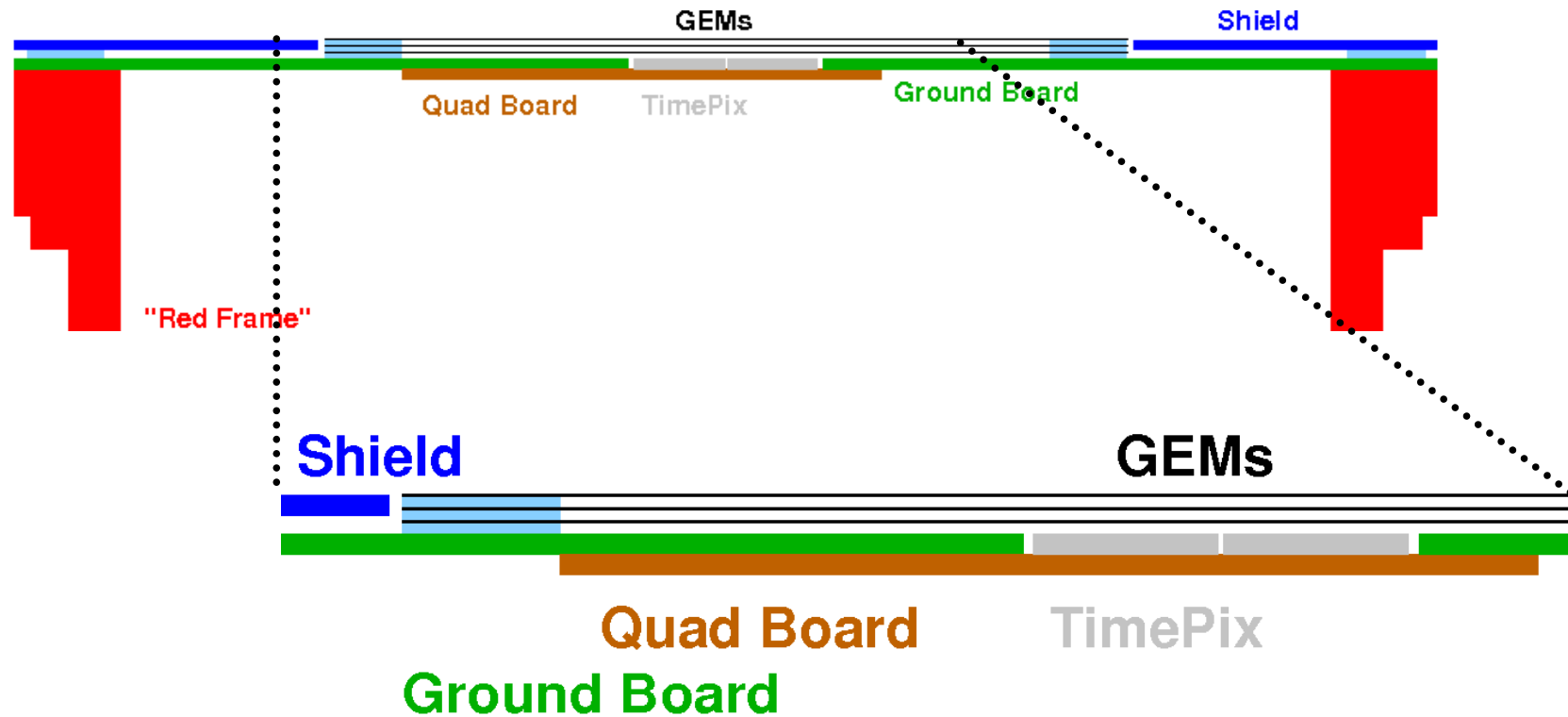
- larger pixels available
- Idea: collect more charge per larger pixel \Rightarrow reduction of effective threshold expected
- FMF in Freiburg is going to prepare a TimePix after first tests with MediPix2

Bonn: TimePix Module for the LP (deliverable by end 2007)

- Based on Medipix2 QuadBoard designed by NIKHEF
- 2x2 TimePix Chips per QuadBoard
- 2 QuadBoards per Module
- QuadBoards glued into PCB back plane

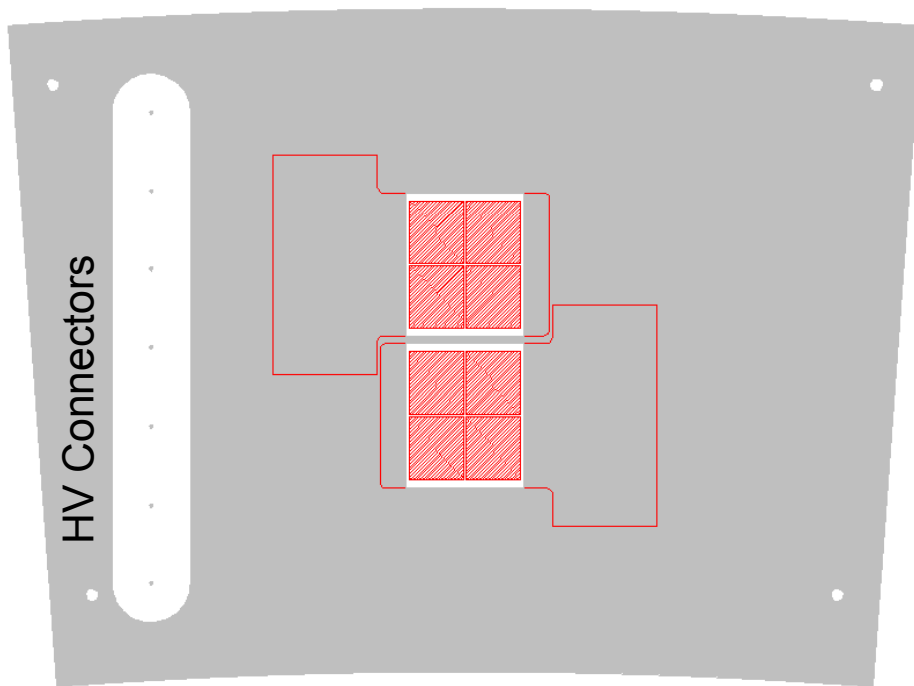


Cross Section

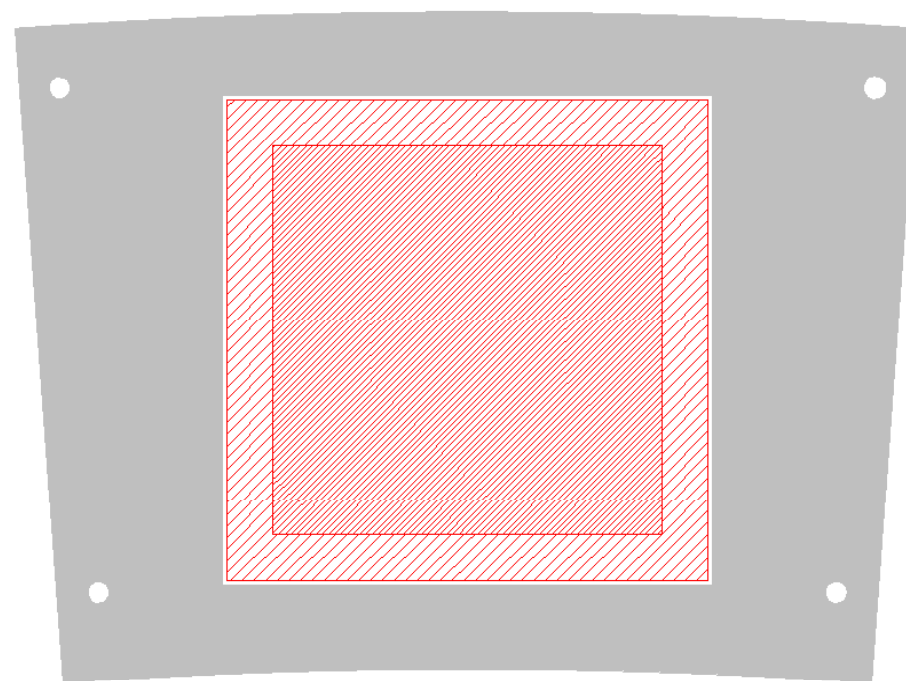


- Three standard CERN GEMs (10x10 mm²)
- Surrounding shield made from a PCB
- 1mm gap between the GEMs
- Total height of active detector:
6mm + connectors

Ground plate with TimePixes

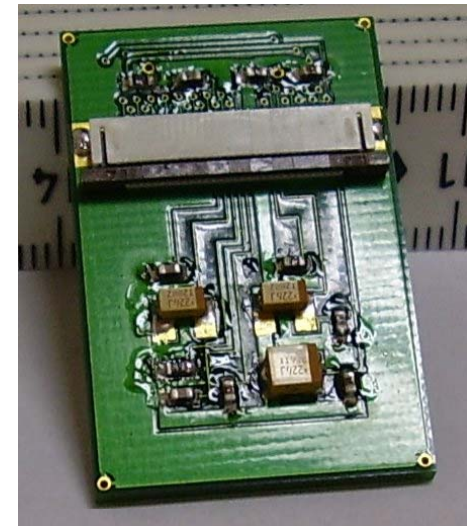
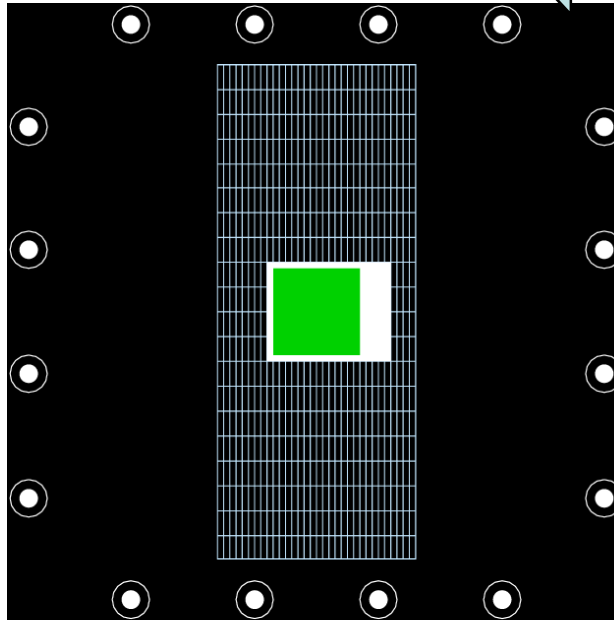
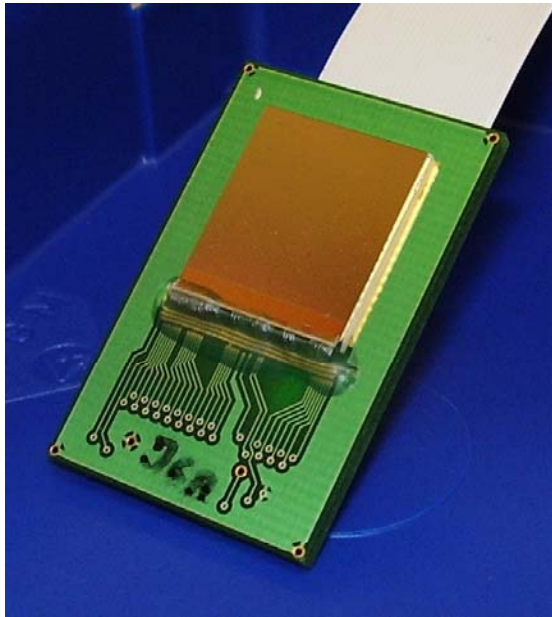


Shield with GEM

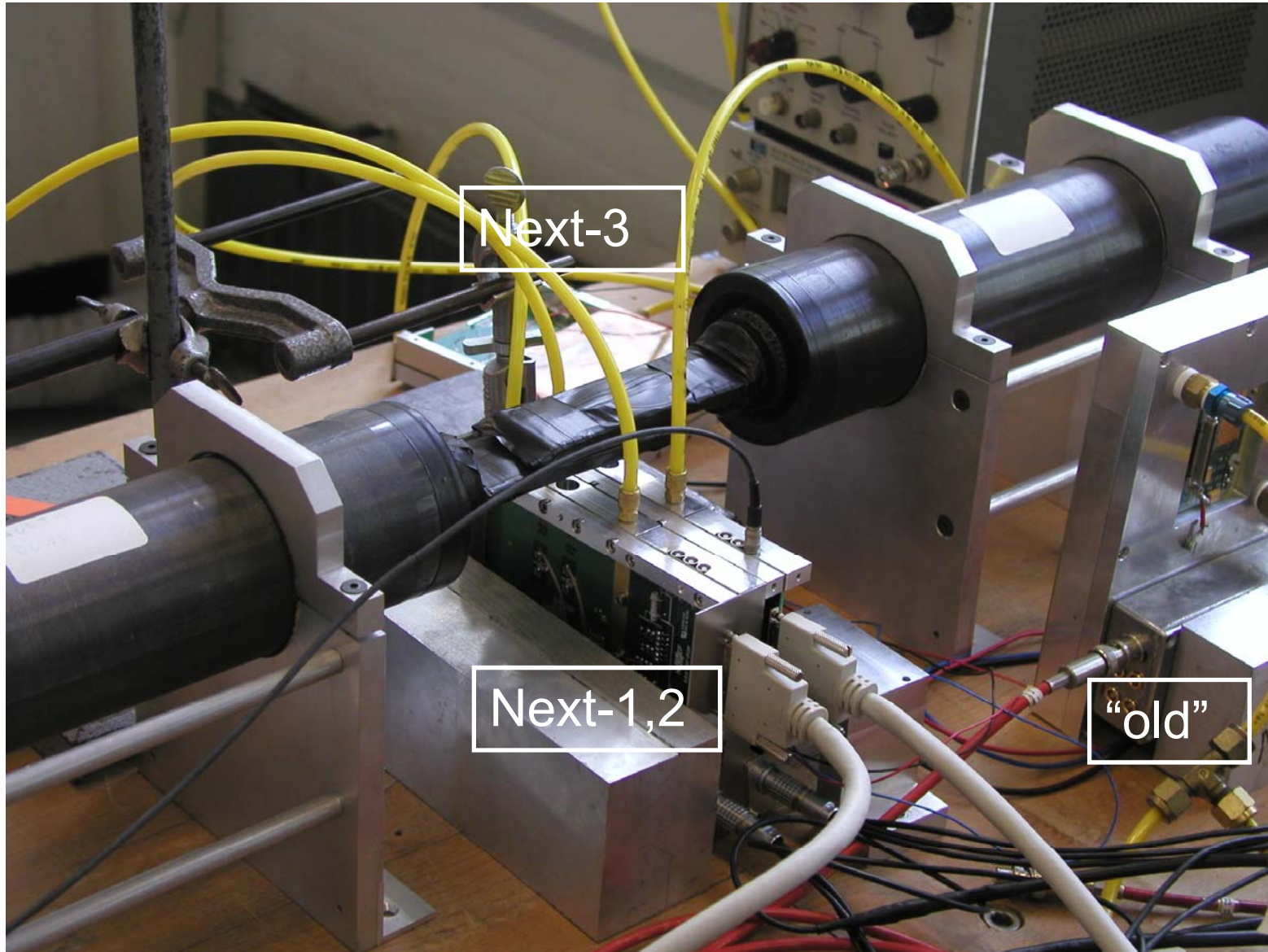


Also: Single Chip Board

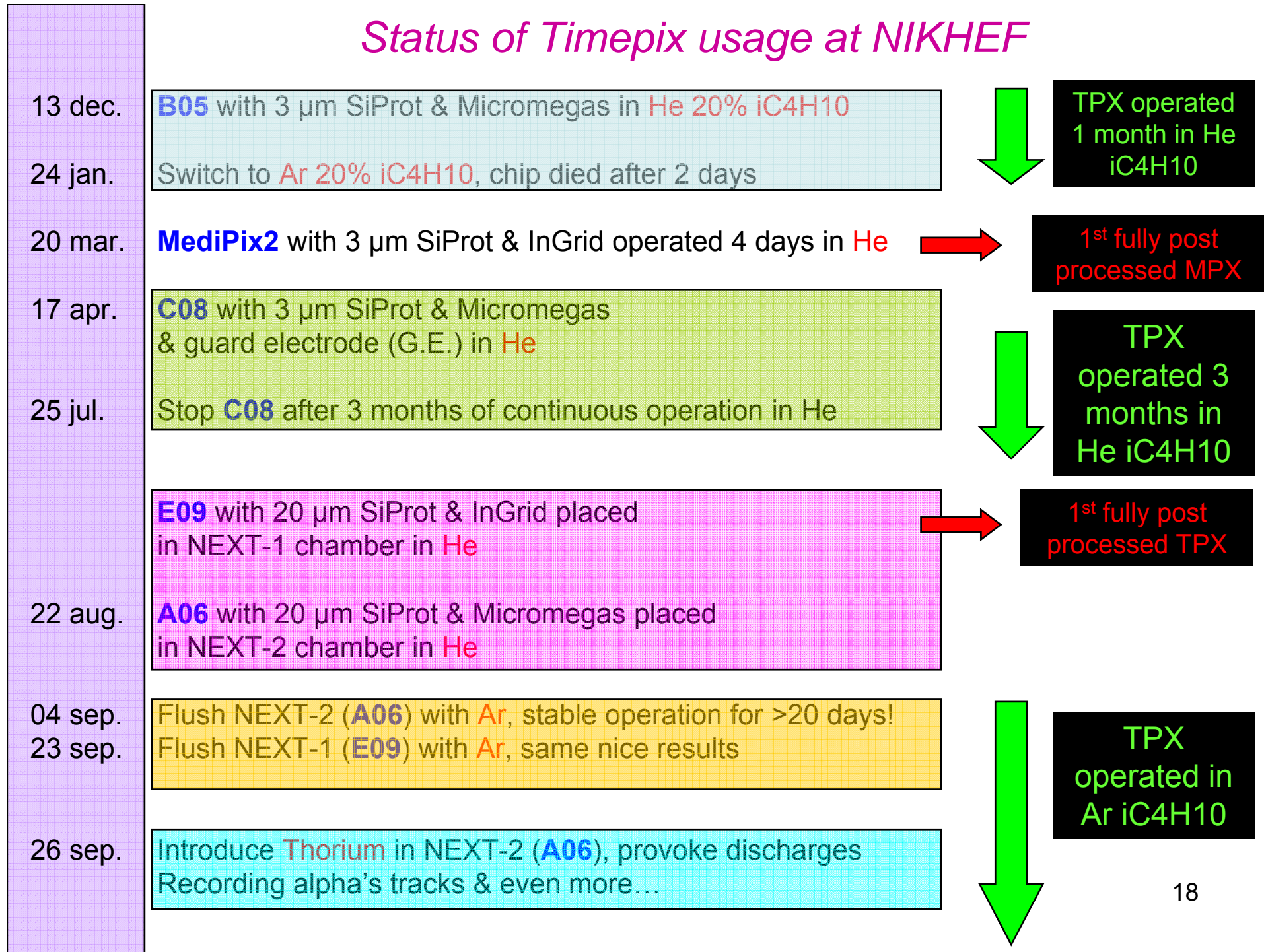
- Designed to be as small as possible:
Resistors mounted behind the chip
- For use in board together with pads



NIKHEF setup (on 24 Aug. 2007)

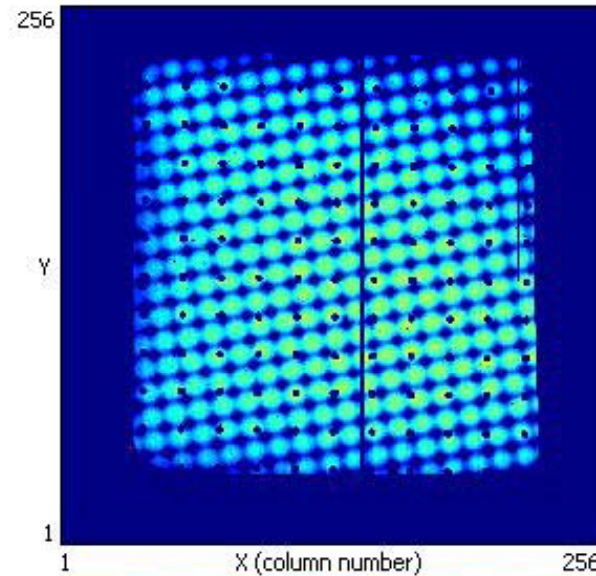
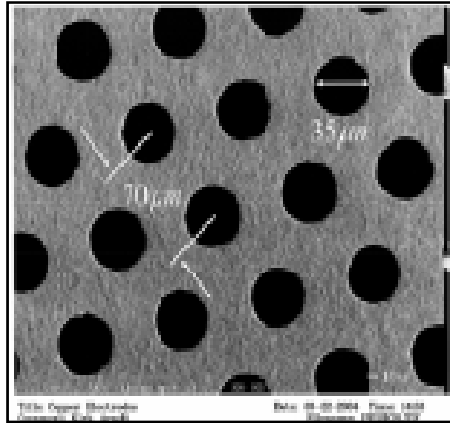


Status of Timepix usage at NIKHEF



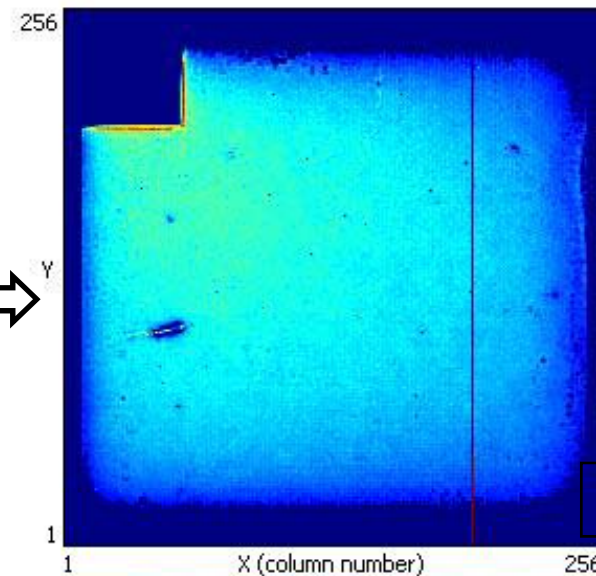
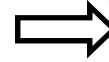
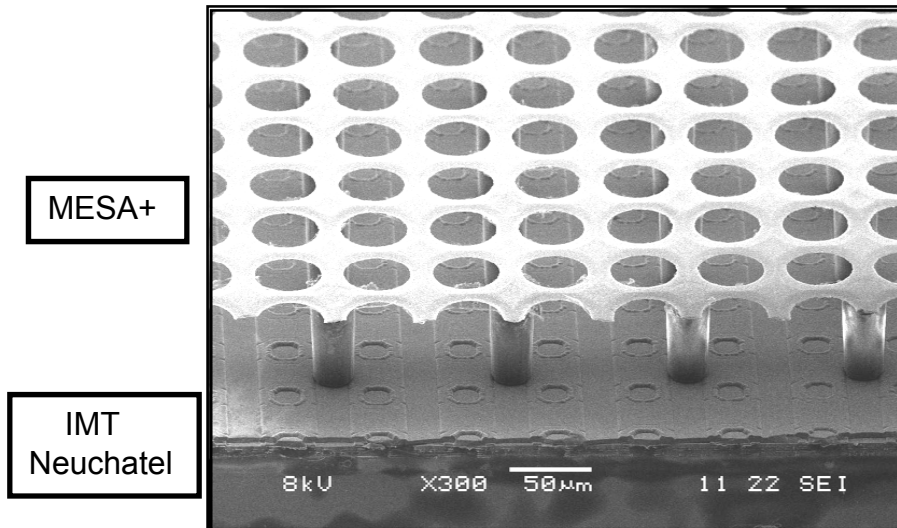
Full post-processing of a TimePix

- Timepix chip + Micromegas mesh:



Moiré effects
+ pillars

- Timepix chip + SiProt + Ingrid:



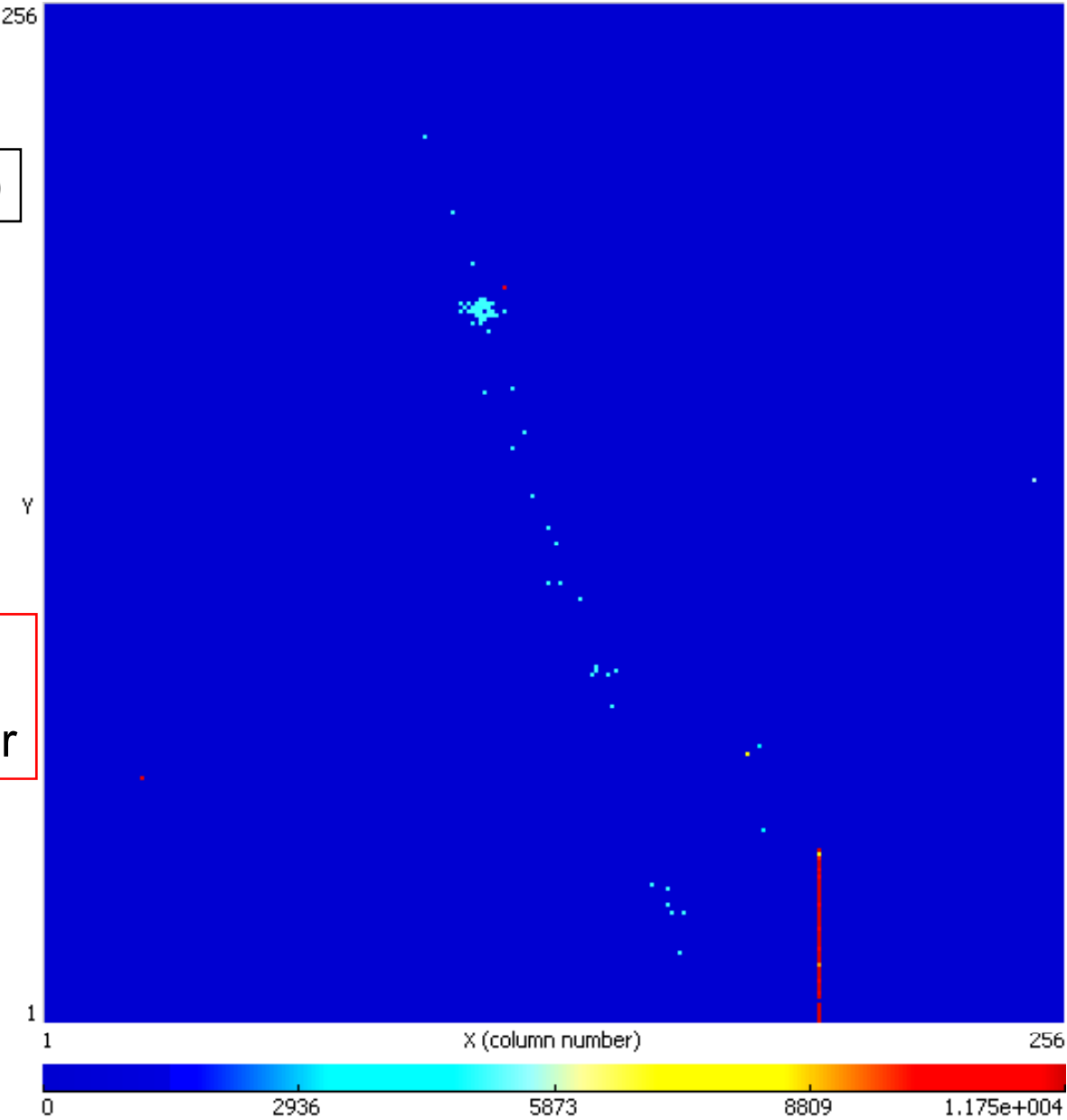
“Uniform”

“counting” mode

^{90}Sr

He/Iso (80:20)

Time mode
118 μs shutter



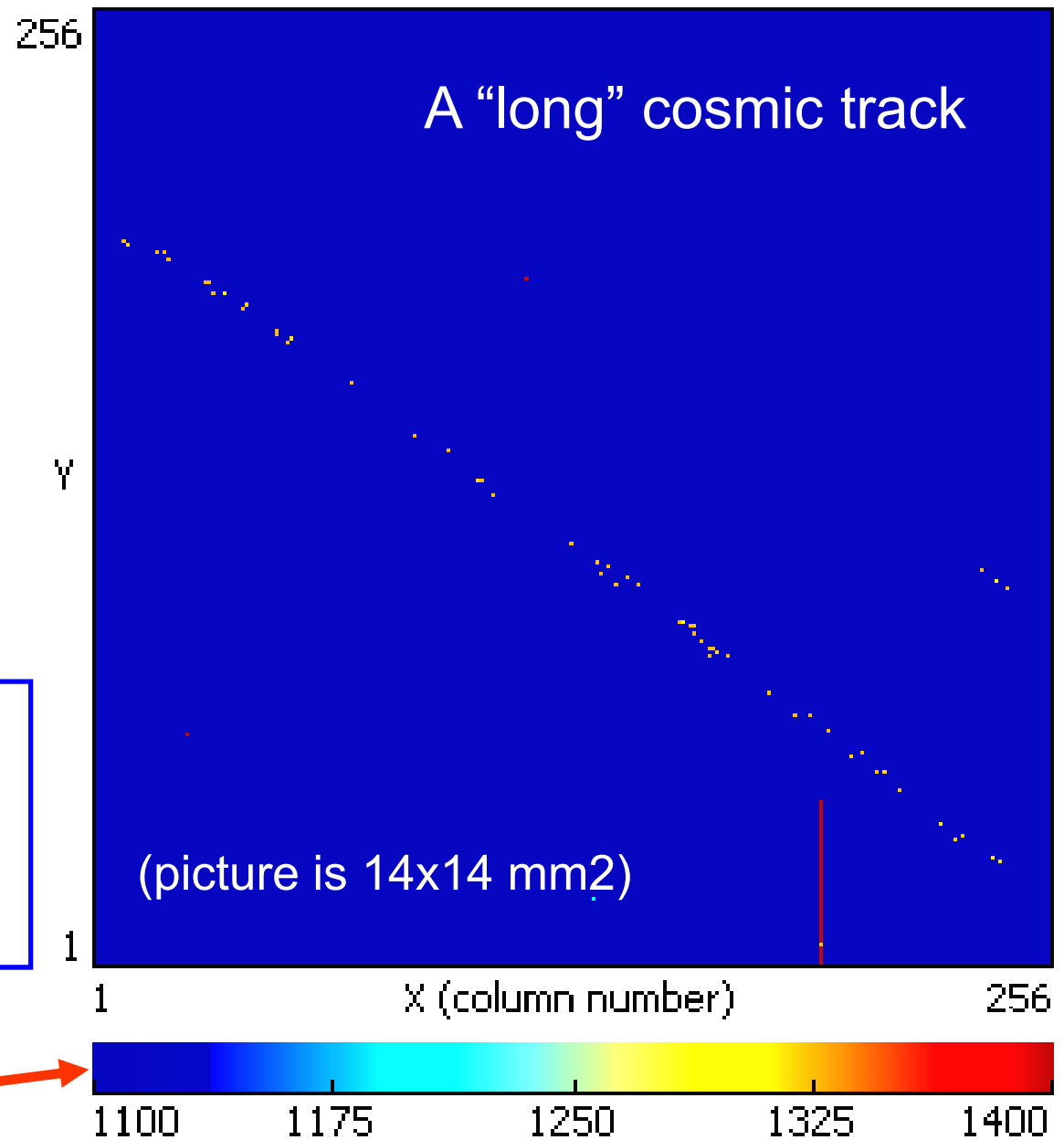
Timepix
+
20 μm Siprot
+
Ingrid
in Next-1

courtesy David Attié

The “typical” track

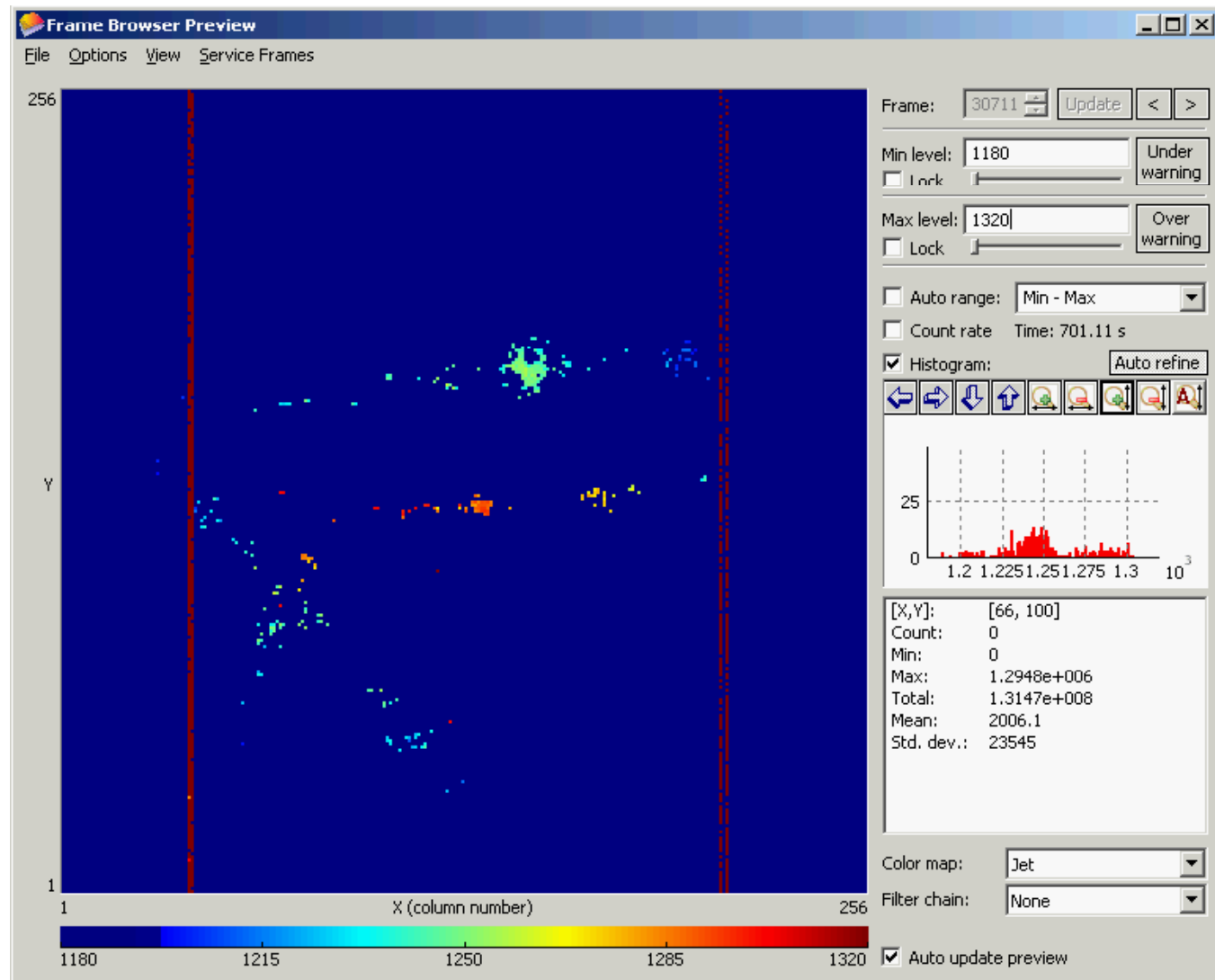
Timepix
+
20 μm thick
Siprot
+
Ingrid

Stable operation in He
iC4H10
Will 20 μm SiProt be
enough to operate in Ar?



Stable operation in Argon too!

Time mode

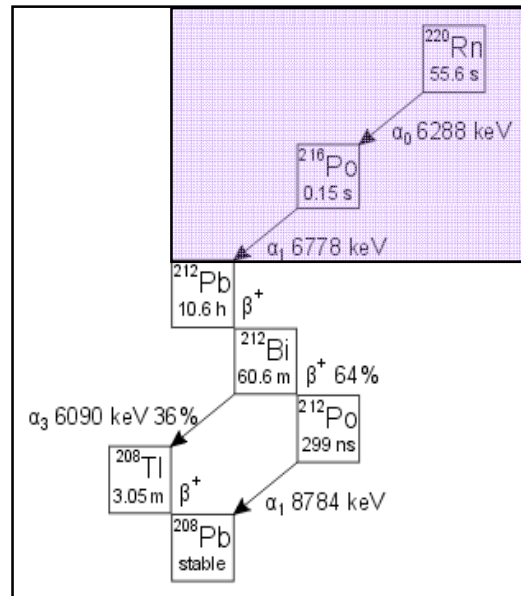


After 2 weeks of cosmic event recording, it was time for a definitive assessment whether 20 μm SiProt is enough to protect against discharges...

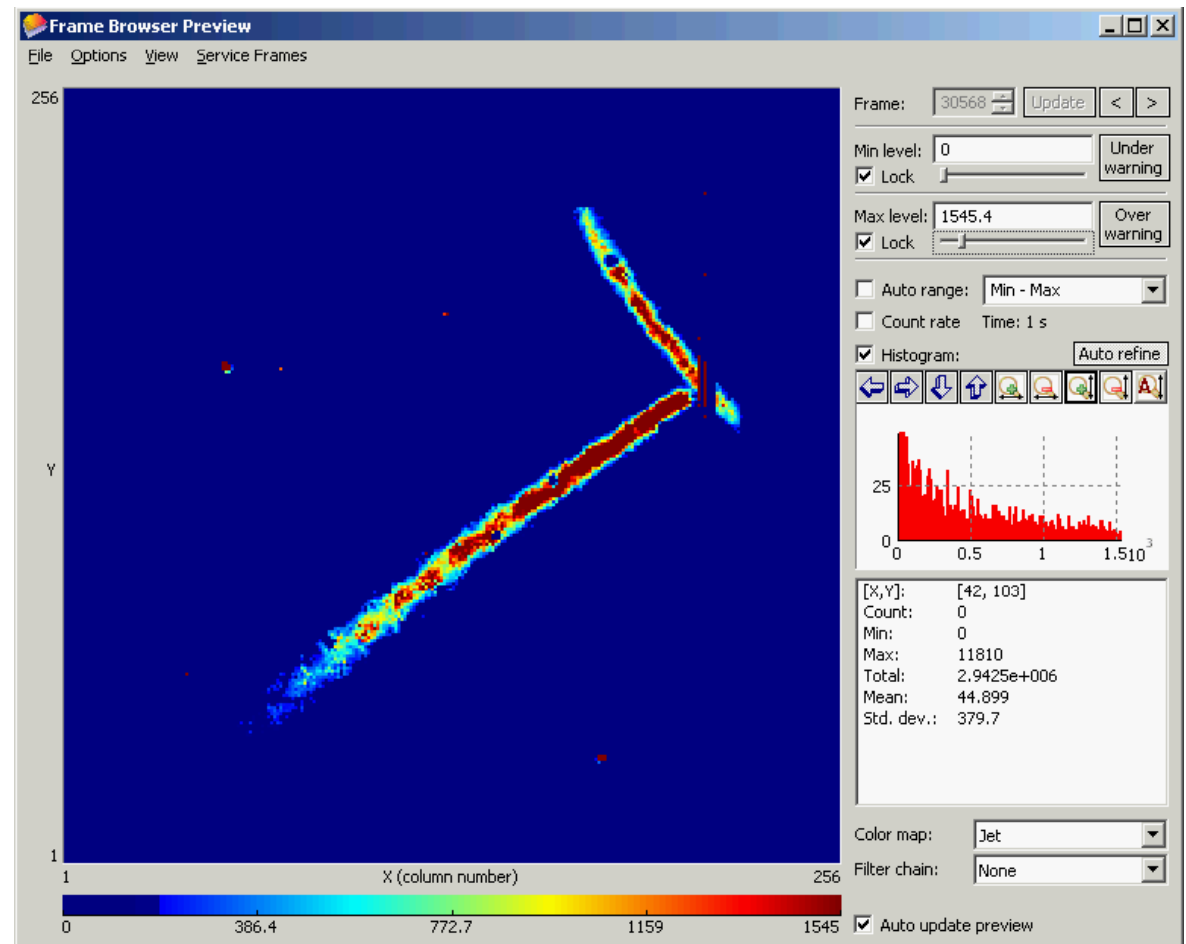
Final assessment: spark-proofness

- Provoke discharges by introducing small amount of Thorium in the Ar gas
 - Thorium decays to Radon 222 which emits **2 alphas of 6.3 & 6.8 MeV**
 - Depose on average $2.5 \cdot 10^5$ & $2.7 \cdot 10^5$ e- in Ar/iC₄H₁₀ 80/20 at -420 V on the grid, likely to trigger discharges

Charge mode



Since 1 week, some $5 \cdot 10^4$ alpha events recorded in 1% of which ...



... discharges are observed !

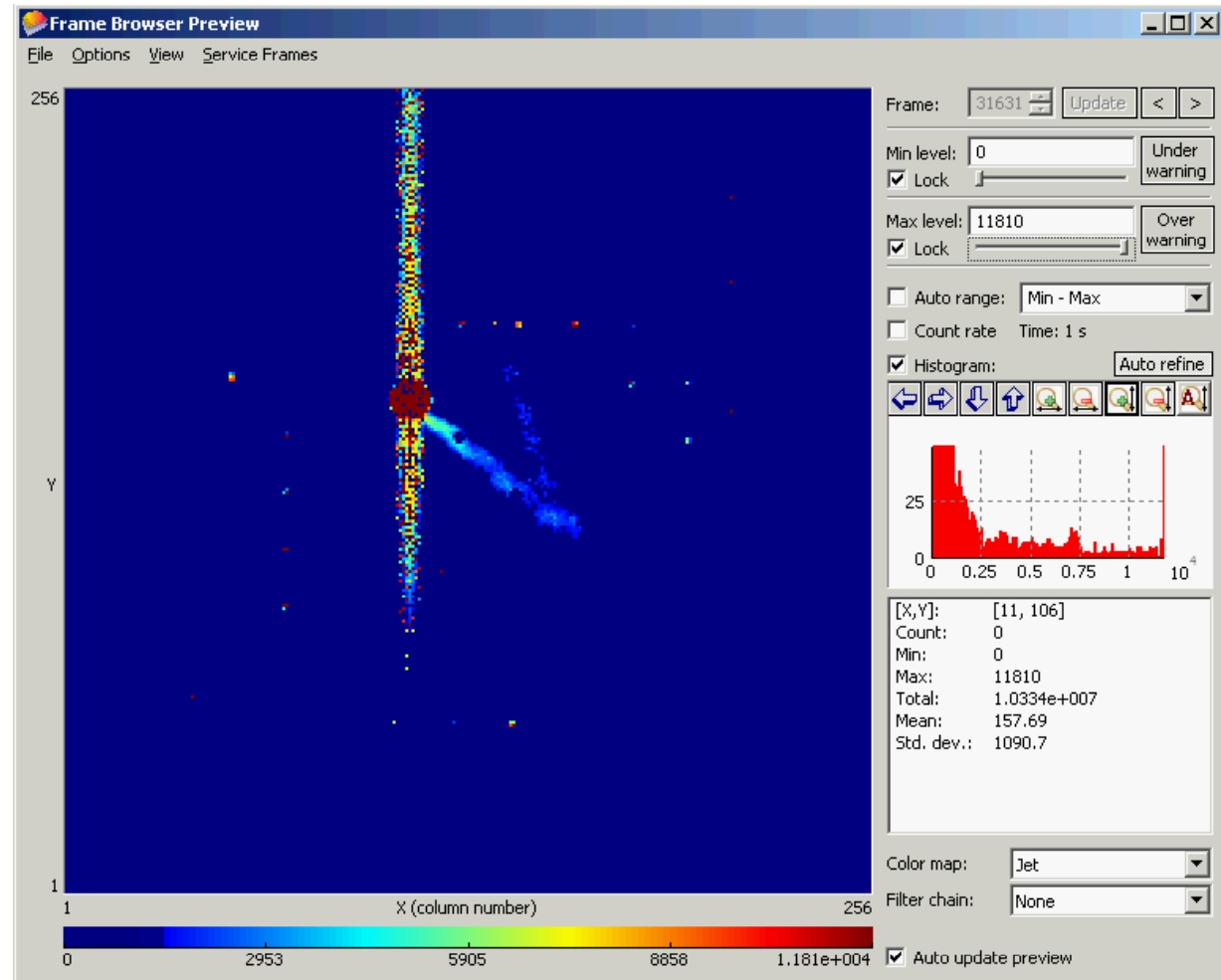
For the 1st time: image of discharges are being recorded

Round-shaped pattern of some 100 overflow pixels

Perturbations in the concerned column pixels

- Threshold?
- Power?

Chip keeps working !!





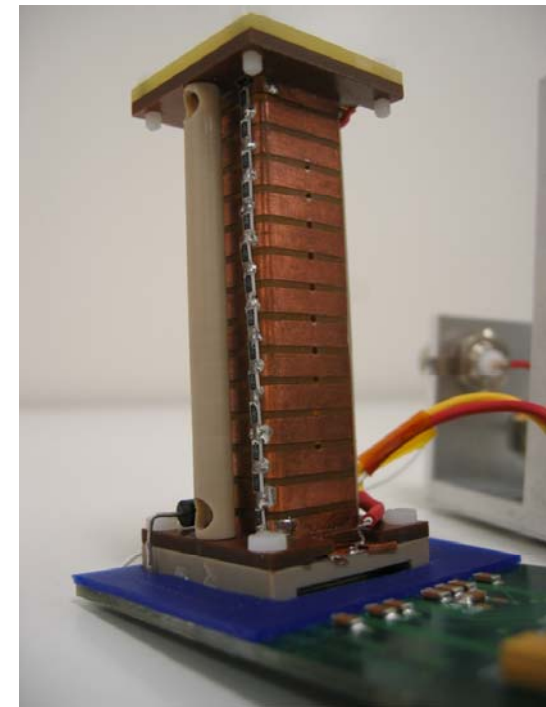
TimePix wafer tests at CERN (together with Freiburg, NIKHEF)

Class	
A	No dead columns
B	1 dead column
C	2 dead columns
D	>2 dead columns
E	Bad DACs
F	Bad Digital Test
Fnt	Not tested

Wafer n°	Location	TimePix classification							Total	
		A	B	C	D	E	F	Fnt	Wafer	A+B
8_A9FWR6X	CERN	31	27	6	11	12	20	0	107	58
9_ACFWR3X	CERN	42	15	13	10	9	17	1	107	57
10_A6FWQ5X	CERN	40	27	7	12	11	9	1	107	67
11_ATFWTLX	CERN	54	18	7	6	14	8	0	107	72
12_ASFWTMX	CERN	45	21	7	2	18	13	1	107	66
13_ARFWTNX	CERN	15	18	14	27	17	16	0	107	33
14_A5FWQTX	Diced	44	26	3	6	8	20	0	107	70
15_AQFWTPX	VTT	55	20	10	6	9	7	0	107	75
16_GX11ILX	CERN	44	27	8	10	13	5	0	107	71
17_G111GIX	CERN	41	31	8	7	14	6	0	107	72
18_GG11G3X	CERN	58	26	5	4	9	5	0	107	84
19_GF11G4X	CERN	49	30	9	6	9	4	0	107	79
20_GV11INX	CERN	51	23	15	13	3	2	0	107	74
21_GV11GPX	CERN	49	27	8	9	9	5	0	107	76
22_GZ11H2X	CERN	48	25	9	7	14	4	0	107	73
23_GU11H7X	CERN	58	26	2	3	12	6	0	107	84
24_GY11IKX	CERN	47	23	8	6	18	5	0	107	70
25_GW11H5X	CERN	46	18	8	15	2	18	0	107	64
26_GS11H9X	CERN	35	39	7	8	11	7	0	107	74
27_GH11G2X	CERN	56	27	5	4	13	2	0	107	83
TOTAL		908	494	159	172	225	179	3	2140	1402
(%)		42,4	23,1	7,4	8,0	10,5	8,4	0,1	100	65,5

20 wafers from the
first run tested
→ ~ ~~66~~% of chips are
usable

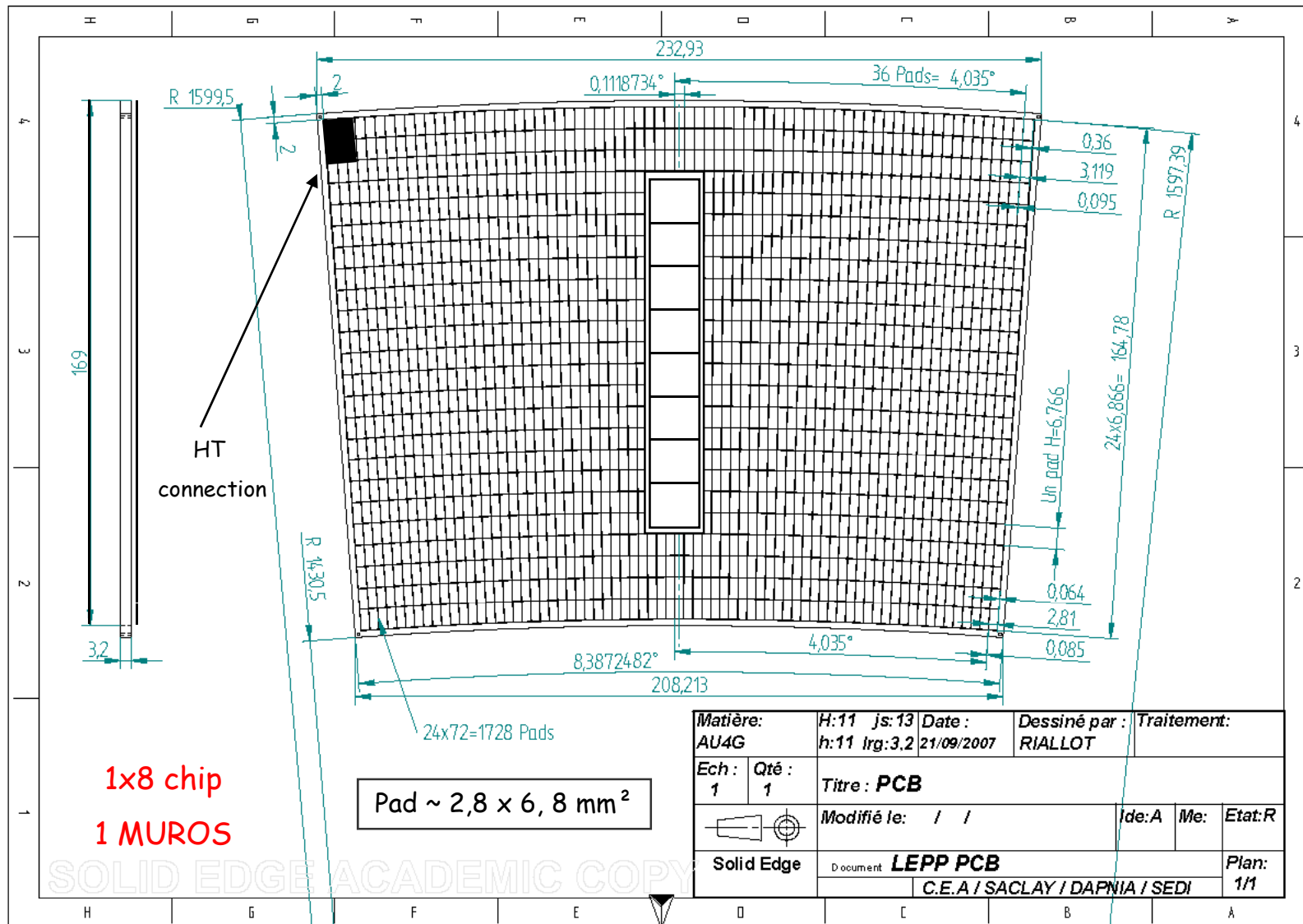
72.9% yield
(A+B+C)

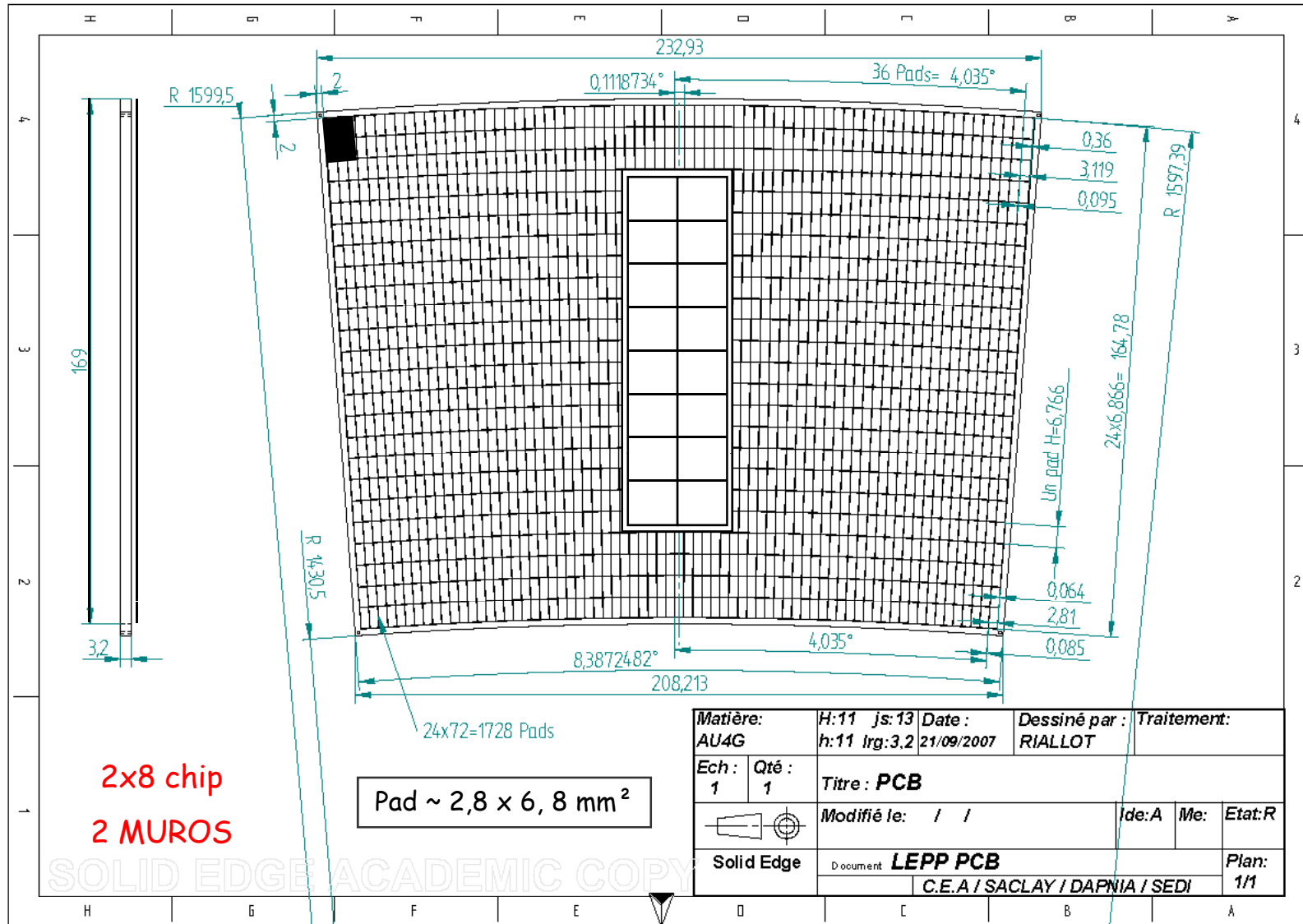


- The field cage is ready to work in He/Iso 80/20
(6 kV on the cathode)
- 1 TimePix dead by HV accident
- 2 TimePix Chip don't show the same behavior after putting up the micromegas mesh
- Several chips with Siprot now available



Deliverable endplate with TimePix





Summary

- A lot of progress made in last year; not mentioned many details on track resolution studies, reconstruction software development, signal development
- Part of the technology is ready
- Discharge protection seems working

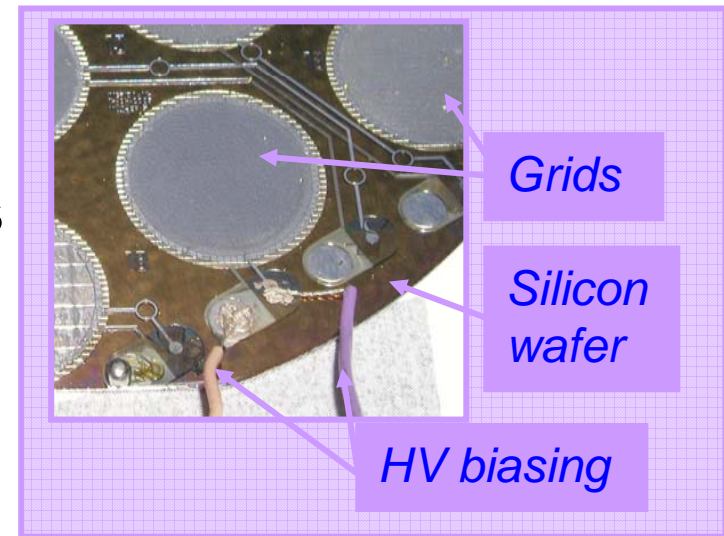
Next:

- Build larger detector systems with fast readout; first step (“deliverable”) endplate structure end of 2007 (few 1-2 months later)
- Further beam tests (and in B field)
- Assess track and dE/dx resolutions

Backup slides

Wafer post-processing(s)

- Idea: use micro-electronic techniques to optimize CMOS pixel chip performances
 - Gas amplification structures
 - Current limiting coatings

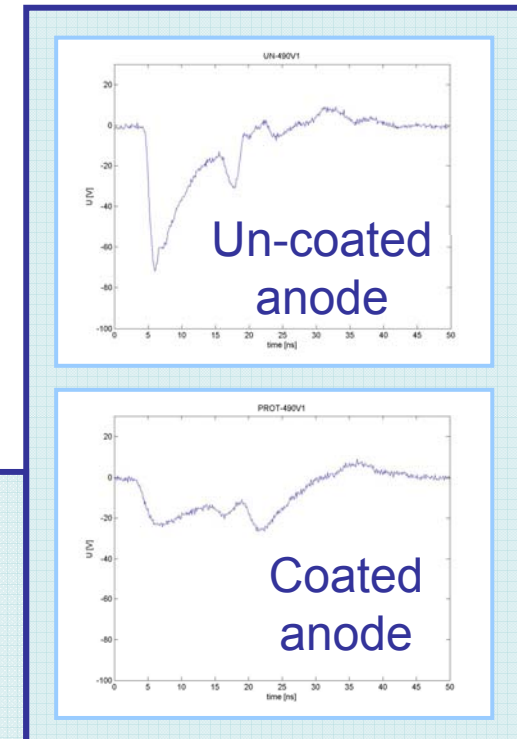


• InGrid: a Grid integrated on Si

- Maximize detection efficiency
 - alignment holes/pads
- Minimize dead areas
 - small pillars Ø, full pixel area coverage

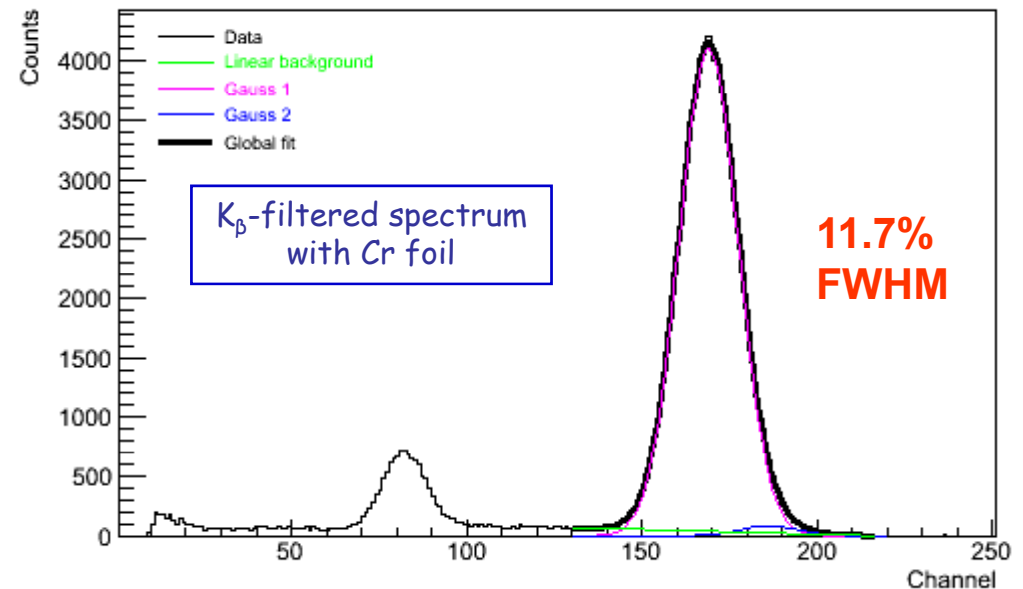
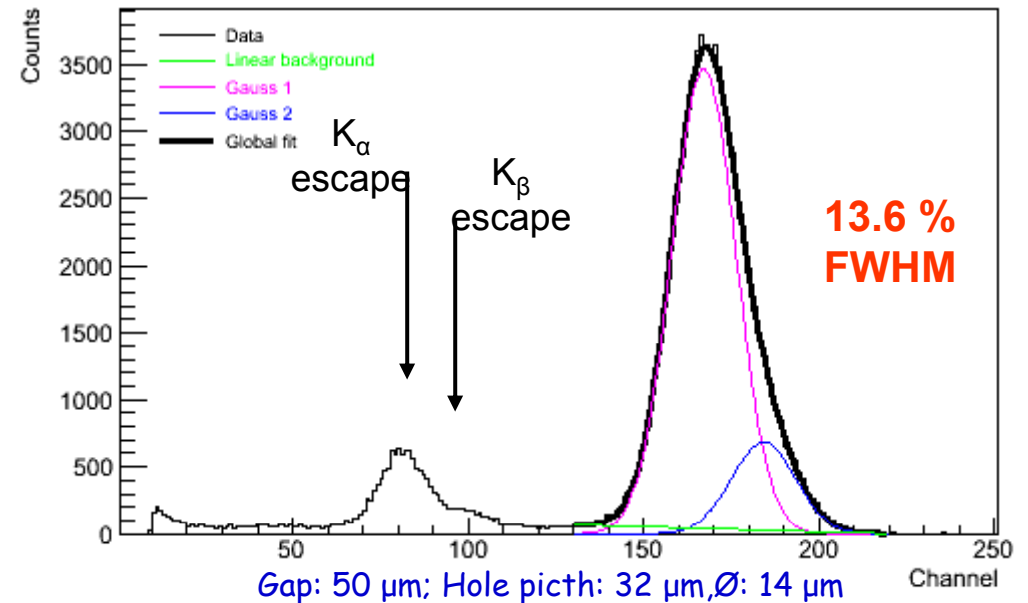
• SiProt: a low T deposited aSi:H layer

- Up to 30 μm thick films, $\sim 10^{11} \Omega\cdot\text{cm}$
- Attenuate discharge current



New Ingrid developments and results

- Process improvement: grids much flatter
 - Extremely good energy resolution:
13.6 % FWHM with ^{55}Fe in P10
 - Removal of K_{β} 6.5 keV line:
11.7 % @ 5.9 keV in P10
- New wafer masks:
hole pitches down to 20 μm
with various diameters and gaps
 - Investigate Micromegas geometry
 - **Test of the ion backflow theory**
- Until now: 1 μm thin Al
but can now be increased to 5 μm by
electrolysis
Expect less damaged from sparks



InGrid ion backflow measurements (I)

- Measurements started in Saclay with D. Attié & P. Colas
- Main issues encountered:

- Gas gap between detector window & cathode

- “Parasitic” field
Unwanted contribution to primary current

- Small grid area

- high X flux for significant primary current
(recombination problem @ low drift field)
- bad collection of “long” range photoe-

- Solutions:

- Operate the detector with cathode at ground

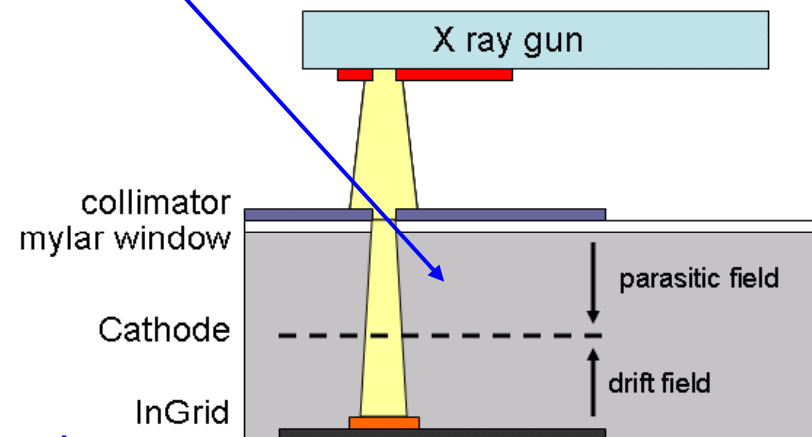
- Reduce X-ray energy (~ 9 keV) and flux

- Now:

- measurements of the primary and backflow currents accurate to the pA!

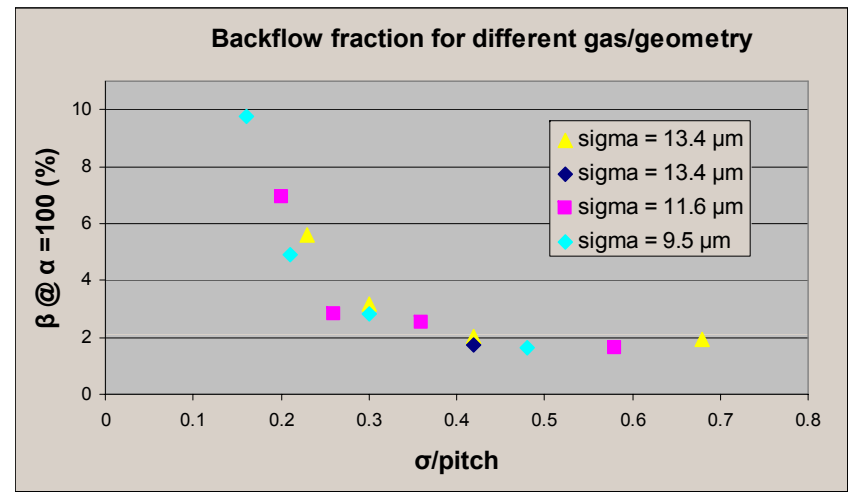
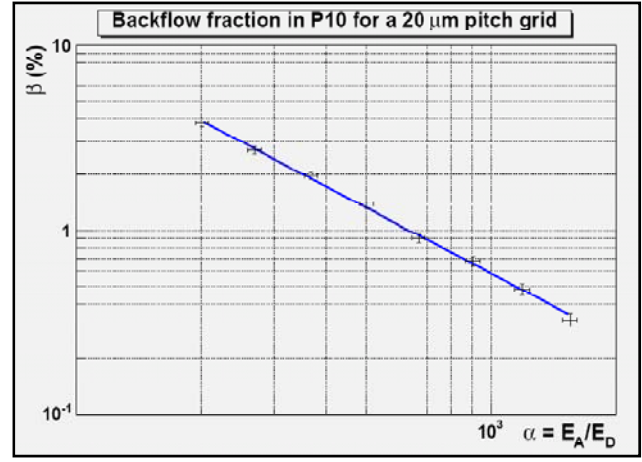
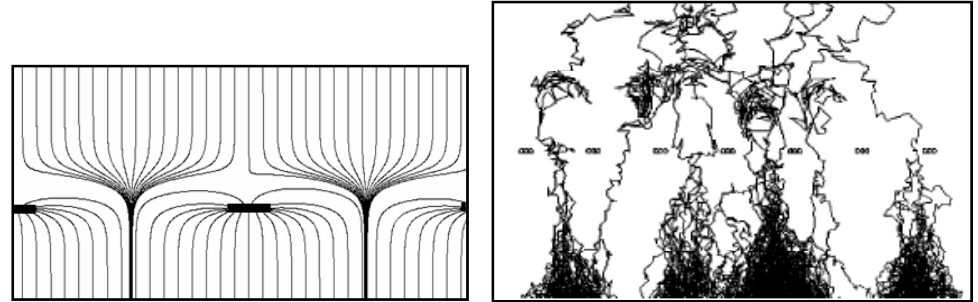
- Good measurements up to field ratio of 1000:

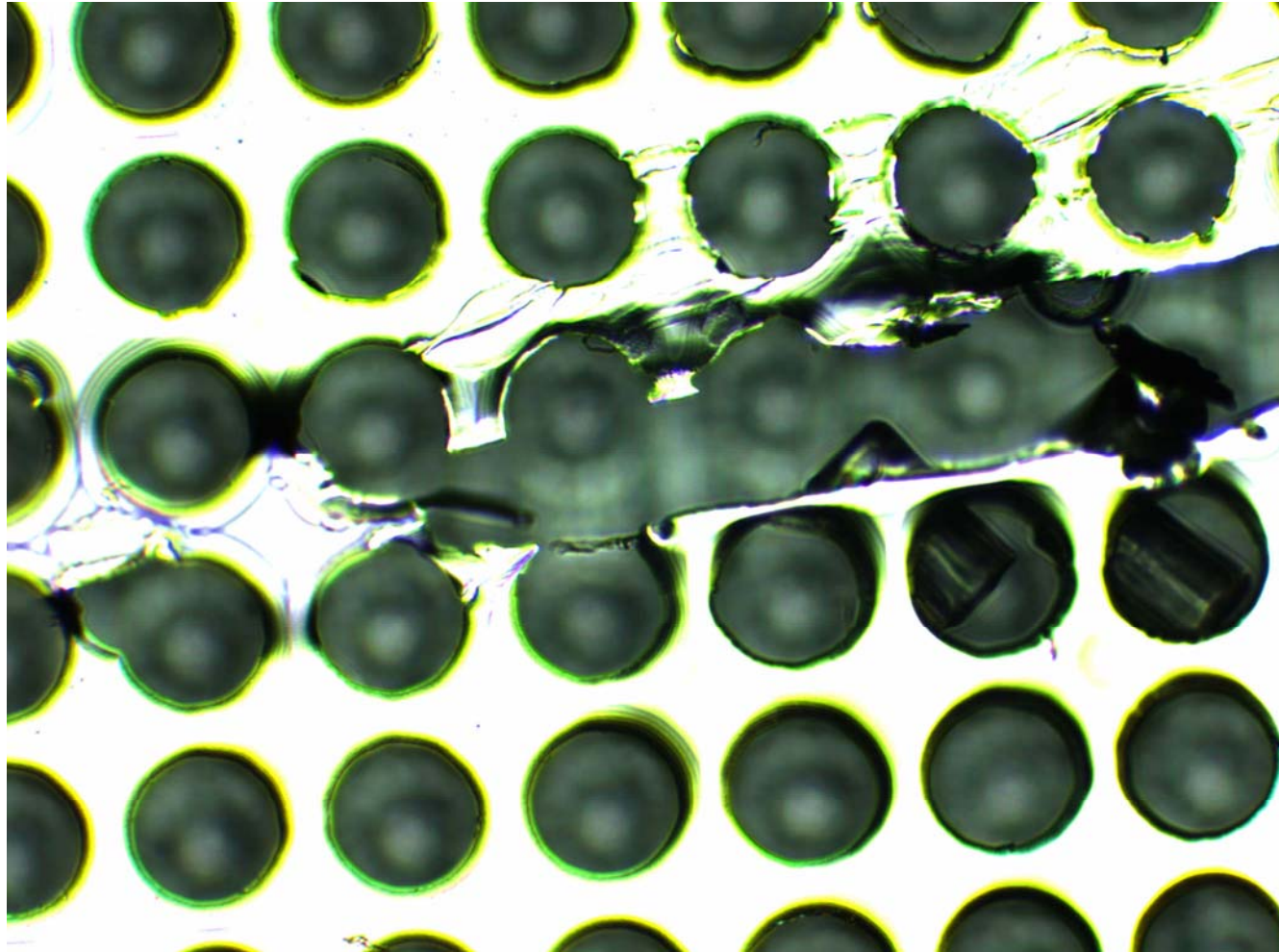
backflow fraction of few 10^{-3} in P10 gas.



InGrid ion backflow measurements (II)

- Phenomenon depends on:
 - Avalanche charge distribution
 - Funnel size
- therefore on the gas and grid geometry
 - Q density in the funnel decreases with the avalanche transverse diffusion
 - Funnel size decreases with the field ratio and hole pitch
- Backflow fraction reaches a (minimum) plateau
 - Occurs when ions backflow through neighboring holes
 - Simulation predicts this to occur at $\sigma/p = 0.5$



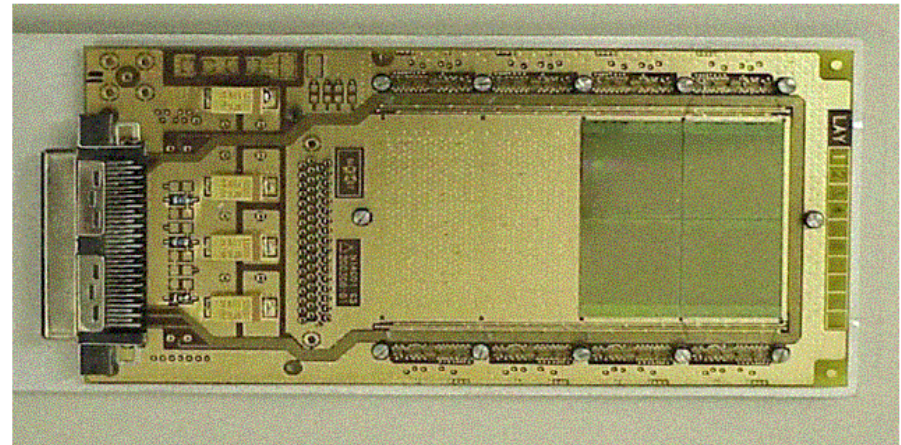


A “scratch” occurred during production Ingrid;
Loose parts removed. Ingrid working!

Further Developments

RELAXD project (Dutch/Belgian)
NIKHEF, Panalytical, IMEC, Canberra:

- **Chip tiling:** large(r) detector surfaces
(2x2, 2x4 chips)
- **Through Si connectivity:** avoiding bonding wires
- **Fast readout technology**
(~5 Gb/s)



Somewhat slower progress than expected:

Still hope for “through Si vias” (with Medipix chips) later this year!

summary timetable

- ✓ 1st version Timepix operational: ~~1/2007~~ 9/2006
- ✓ First m.i.p. signals with Timepix: ~~~4/2007~~ 11/2006
- Gain experience with Timepix during 2007
- Development 2nd iteration Timepix during ~~2007~~
→ 3/2008
- Endplate infrastructure: 1/2008
- Full SITPC infrastructure incl. DAQ available:
1/2009

TimePix Reconstruction



Data Structure	Processor Name	Collection Name
TrackerRawData		TimePixRawData
	TimePixZeroSuppressionProcessor	
TrackerRawData		TimePixZeroSuppressedRawData
	TimePixClusterFinderProcessor	
TrackerHit		TimePixHitCandidates
	TimePixClusterProjectionSeparatorProcessor	
TrackerHit		TimePixSepHitCandidates
	TimePixHitCenterCalculatorProcessor	
TrackerHit		TimePixHits

